

Charge collection and laser measurements on double-sided 3D strip sensors irradiated up to $2 * 10^{16} n_{eq} / cm^2$

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23rd RD50 workshop, CERN, 2013.11.15

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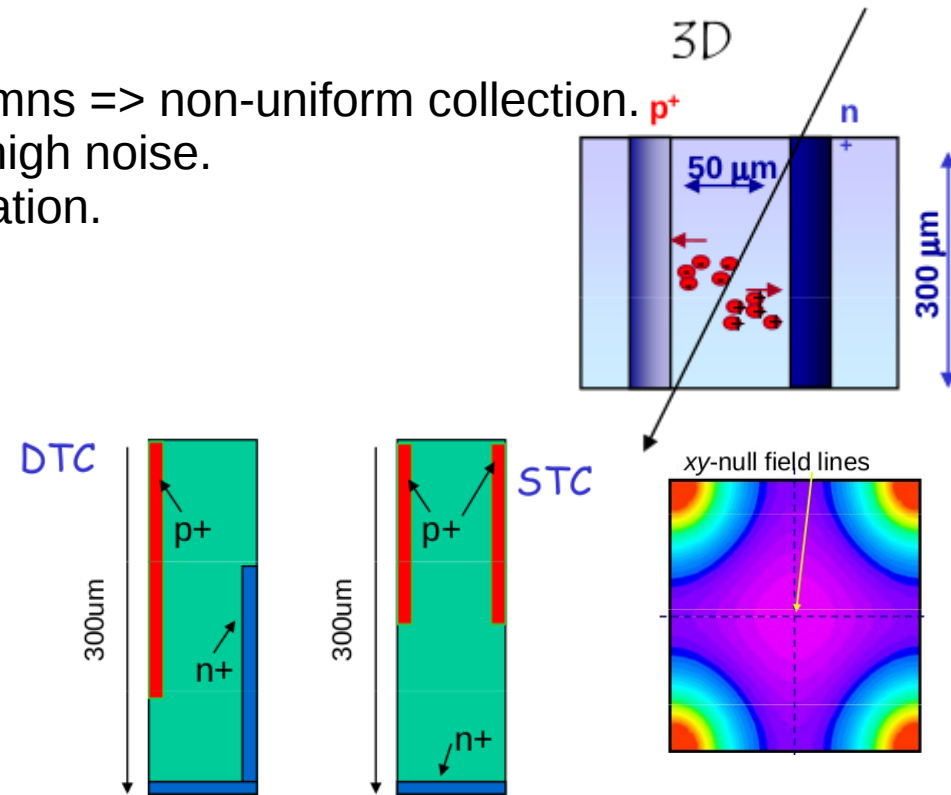
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4: Fondazione Bruno Kessler, Centro per i Materiali e i Microsistemi (FBK-CMM), Italy.

- **Introduction:**
 - recent studies;
 - Motivations;
 - looking forward...
- **Materials:**
 - sensors;
 - set-ups.
- **Methods:**
 - calibration;
 - measurements: I-V, punch-through, β -source, laser;
 - analysis details.
- **Experimental results and discussion:**
 - I-V and punch-through;
 - β -source;
 - laser.
- **Summary and outlook.**

Recent studies:

- 3D sensors main features:
 - Short “collection”-path, long “generation”-path => radiation-hard (up to $5 \cdot 10^{15}$ n_{eq}/cm^2 and beyond[1]).
 - Dead zones between same type columns => non-uniform collection.
 - Narrow bulk => high capacitance => high noise.
 - Complex layout => challenging fabrication.
- Technologies:
 - Original 3D[2]:
 - Exploit of the advantages.
 - Complexity.
 - Single-type column (STC):
 - Much simpler.
 - Large dead zones.
 - Double-type columns (DTC):
 - Better performances than STC.
 - Simpler than the originals.
- Charge multiplication observed[3].
- First production of 3D pixels accomplished at FBK and CNM with DTC [4].



[1] *The ATLAS IBL Coll., Jinst 7, 2012.*

[2] *Dalla Betta et al., PoS Vertex 2012, 2012.*

[3] *Köhler et al., NIMA 659, 2011.*

[4] *Da Via et al., NIMA 649, 2012.*

• Motivations:

- Test radiation hardness up to higher fluences in view of the HL-LHC
 - => Samples highly irradiated.
 - Despite the higher noise, test the signal to noise ratio (at those fluences):
 - => β -source measurements.
 - Interest on the spatial uniformity with the improved technology:
 - => laser measurements.

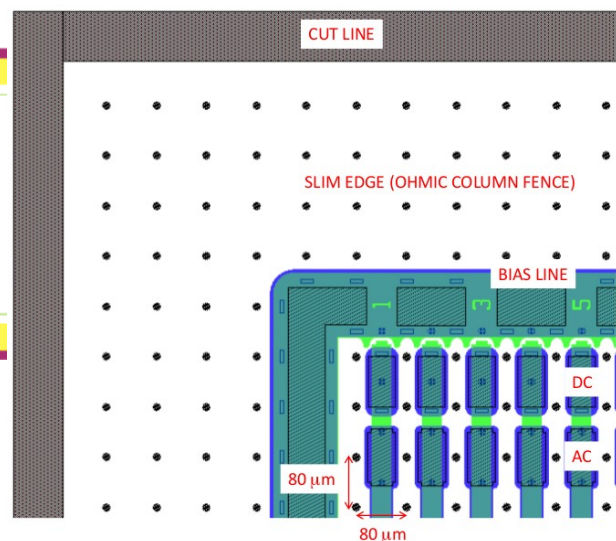
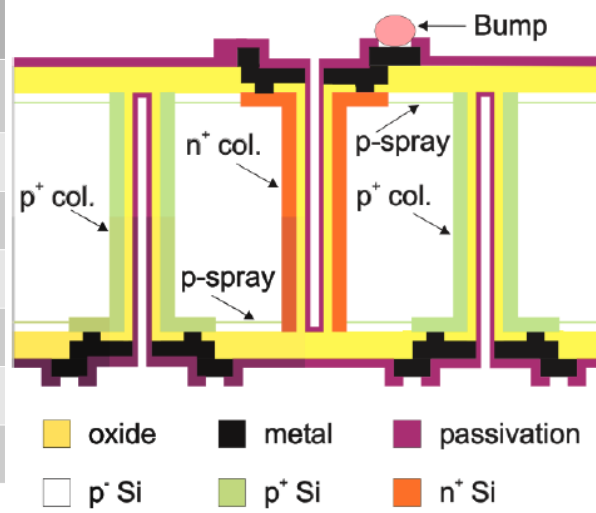
• Looking forward...

- How to exploit the charge multiplication?
- How important is the non-uniformity?
- Is a new technology required?

• Samples[1]:

- Double-sided 3D strip sensors (FBK ATLAS production wafers [2]).
(Strips => easier testing with standard readout electronics.)
- 4", FZ, <100>, p-type, 230+/-20 um thickness, ~20 kΩ*cm.
- 102 strips ~8 mm length, with 80 um pitch between same type columns and 40√2~56 um between different column types, slim edges.
- Columns passing completely through the substrate, ~11 um diameter, not filled by polysilicon.
- P-spray, front side strip connection by n+ diffusion (AC coupling, punch-trough biasing but readout with R-C fanins) or combination of metal and diffusion (DC coupling, readout by R-C fanins).
- Irradiated at 25 MeV protons (NIEL hardness factor of 1.85) at the Karlsruhe Compact Cyclotron (annealing only due to holding during experiments).

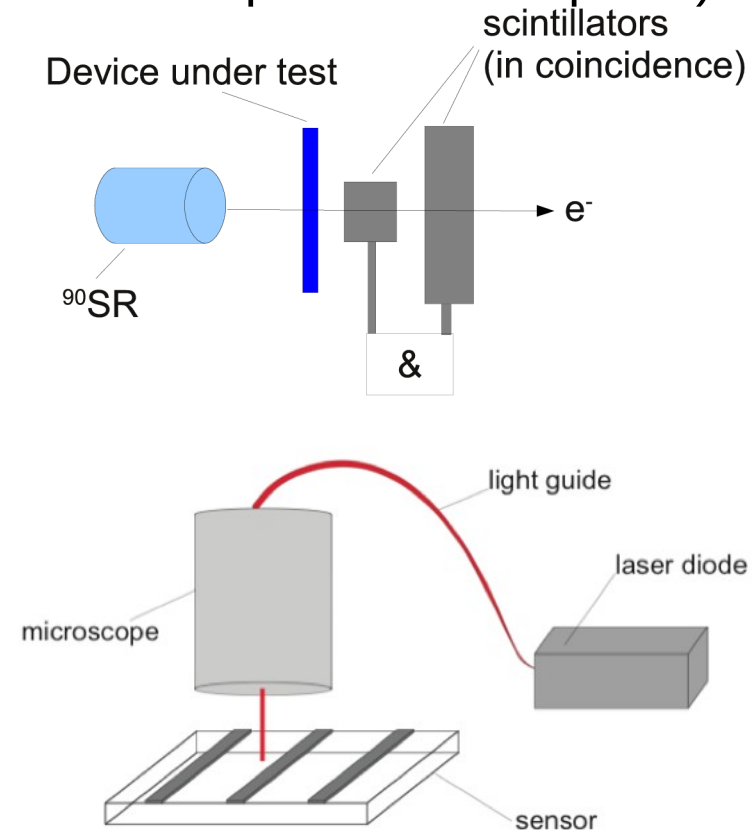
Sensor	Fluence	Coupl.
ID	[n_eq/cm^2]	
W19_SD2	2×10 ¹⁵ +/-10%	AC
W21_SD2	2×10 ¹⁵ +/-10%	AC
W24_SD1	5×10 ¹⁵ +/-10%	AC
W24_SD2	5×10 ¹⁵ +/-10%	AC
W19_SD3	2×10 ¹⁶ +/-10%	DC
W21_SD3	2×10 ¹⁶ +/-10%	DC



[1] M. Povoli et al., NIMA 730, 2013.
 [2] Da Via et al., NIMA 649, 2012.

• Set-ups:

- I-V:
 - Standard probe station, before, through AliBaVa, after irradiation.
- Punch-through:
 - Stated the very high resistance before punch-trough, measurements made with a custom circuit (inverted amplifier with operational amplifier).
- β -source:
 - AliBaVa (Beetle chip).
 - 37 Mbq ^{90}Sr source.
 - 2 scintillator in coincidence.
- Laser:
 - AliBaVa.
 - 974 nm \Rightarrow ~ 90 μm penetration depth, ~ 4.5 μm FWHM.
 - Horizontal plane motorized stage.
- Simulations:
 - TCAD with Synopsis Sentaurus, modified “Perugia” model [1].



[1] Pennicard et al., NIMA 592, 2008.

• Procedures:

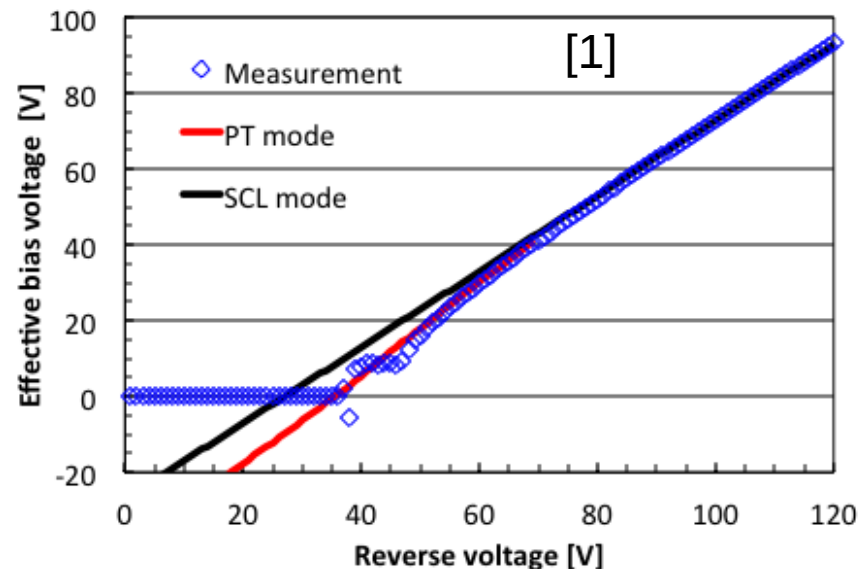
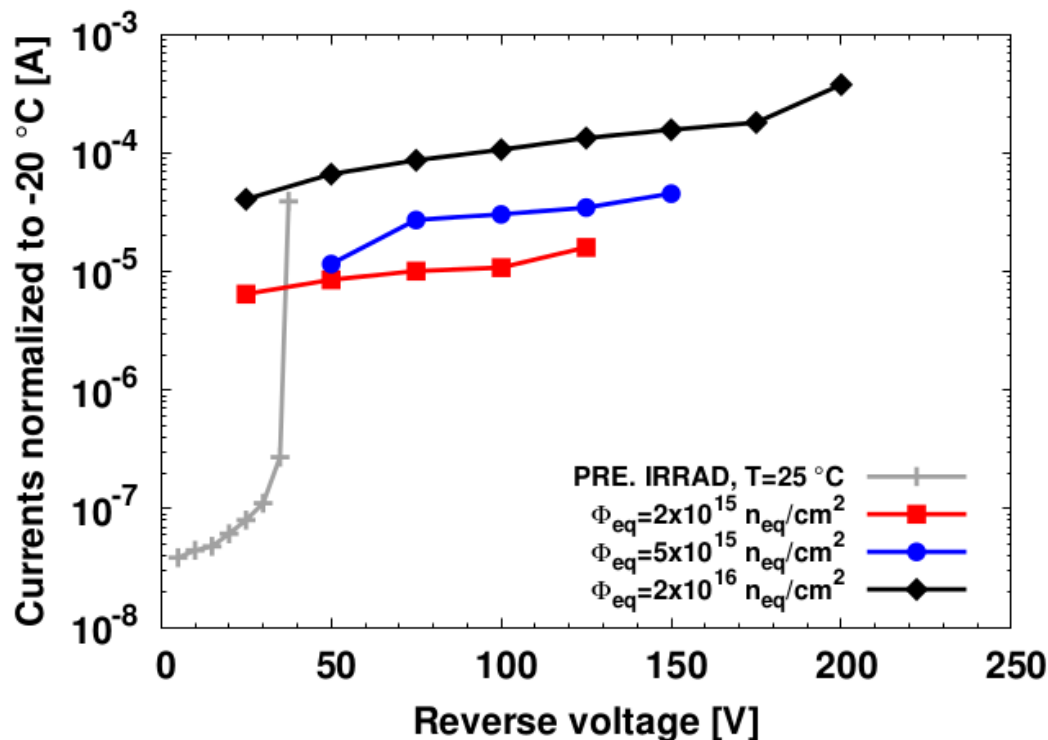
- β -source:
 - Calibration:
 - Sample: unirradiated sensor of known thickness.
 - Method: MPV vs. temperature; assumption of the generated charge ($0.027\ln(\text{thick.})+0.176$ [1]); linear fit of the gain vs. temperature.
 - Measurements:
 - AliBaVa “kazu” configuration (>25 ns peaking time); $T \in [-41, -27]$ °C, $RH < \sim 10\%$.
 - Runs: pedestals+noise+source, at different voltages.
 - Analysis details:
 - Residual cut < ~ 70 strips; time cut = 10 ns around the peak; Clustering: seed cut also down to 2, neighbour cut also to 1.5 (maintaining clear signal).
- Laser:
 - No calibration => relative measurements.
 - Measurements:
 - AliBaVa standard configuration (~ 25 ns peaking time); $T < -35$ °C, $RH < \sim 10\%$.
 - Runs: pedestals+noise+synch.+scan, at different voltages.
 - Analysis details:
 - Sometimes realignment/rebinning (bilinear interpolation, 1-order).
 - Representation of the sum of two neighbour strips or a single strip.

[1] Meroli et al., *Jinst* 6 P06013, 2012.

Experimental results and discussion

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I-V and punch-through:



$$\bullet \alpha = \Delta I / (V * \Phi_{eq}) = 3.3 \div 3.7 * 10^{-17} \text{ A/cm.}$$

$$\bullet V_{BD} = 40 \rightarrow 125 \div 175 \text{ V.}$$

$$\bullet V_{PT} \sim 50 \text{ V.}$$

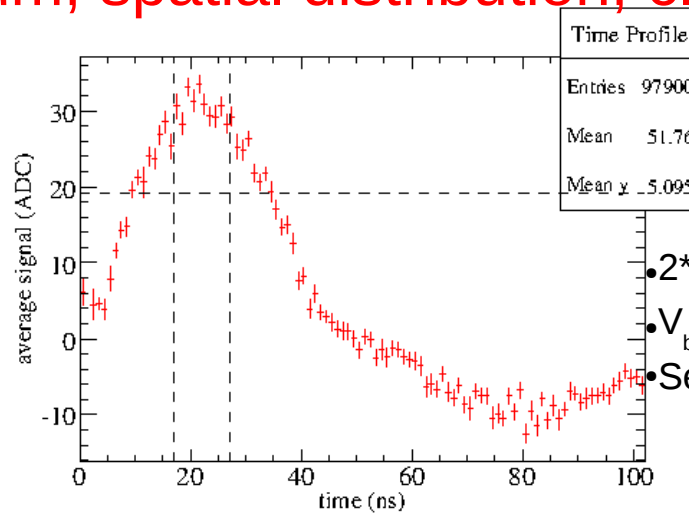
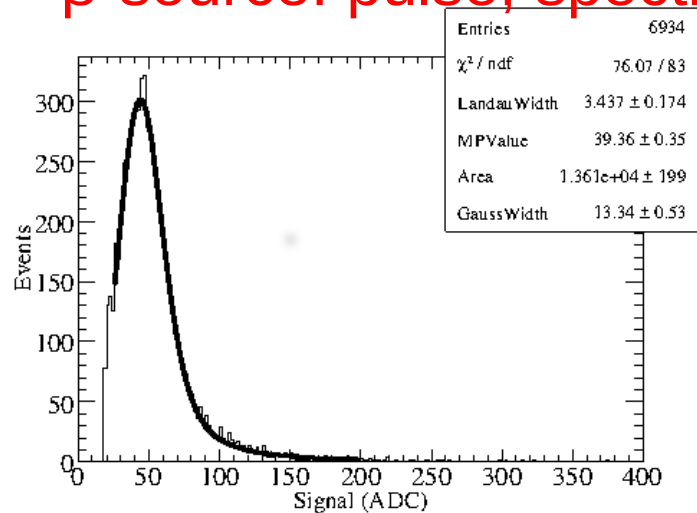
- Leakage current and break-down voltage increase with the fluence as expected.
- Punch-through biasing still effective after irradiation.

[1] Betancourt et al., IEEE TNS 59(3), 2012.

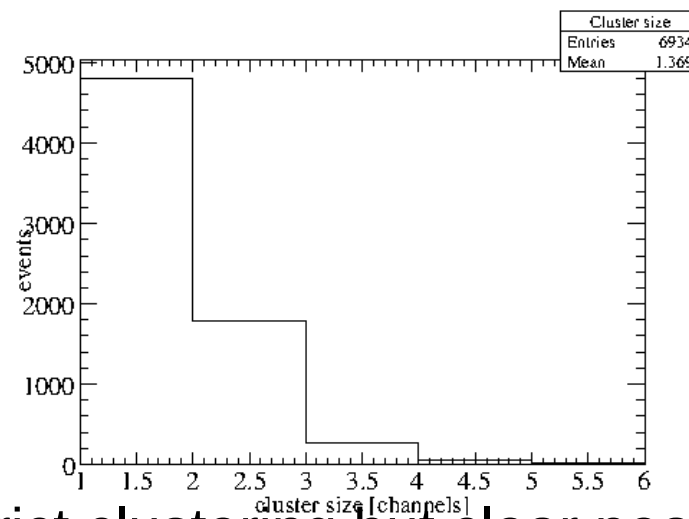
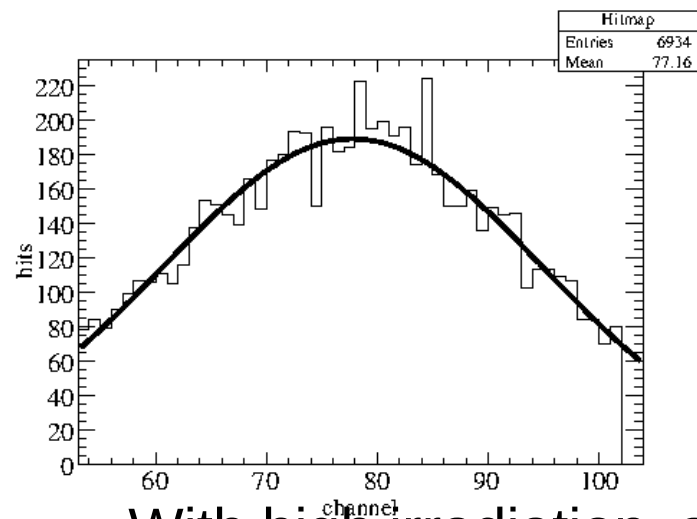
Experimental results and discussion

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• β -source: pulse, spectrum, spatial distribution, clustering



- $2 \cdot 10^{-16} \text{ n}_{\text{eq}} / \text{cm}^2$.
- $V_{\text{bias}} = 200 \text{ V}; -30 \pm 1 \text{ }^\circ\text{C}$.
- Seed cut=3.5, neighbour cut=3.

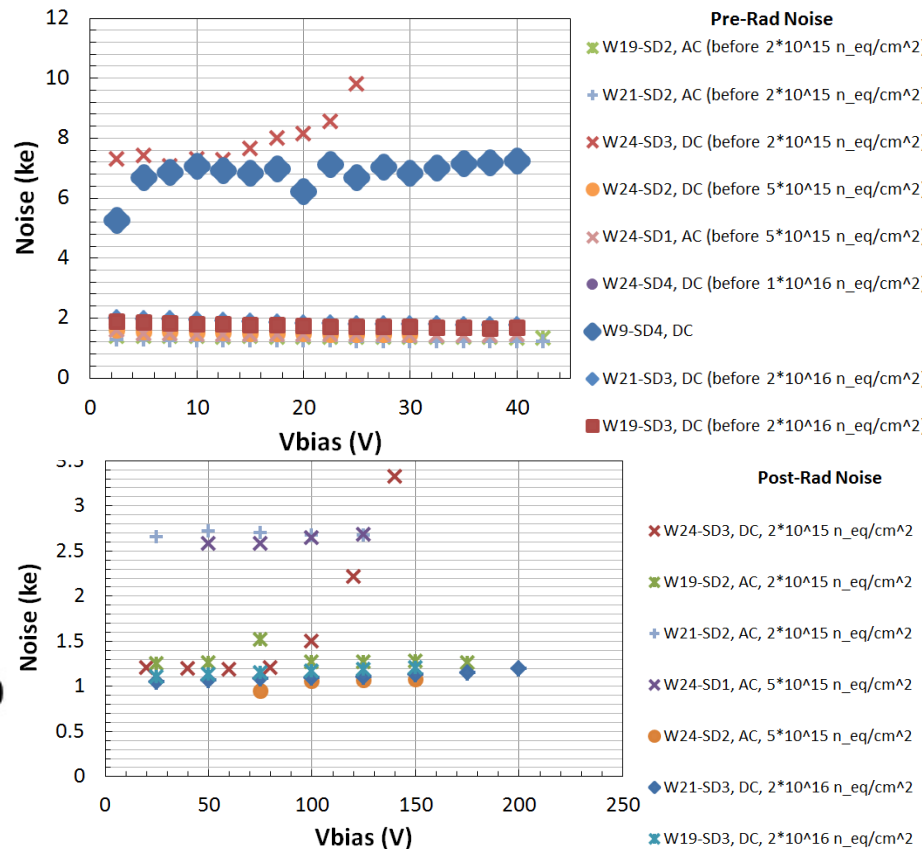
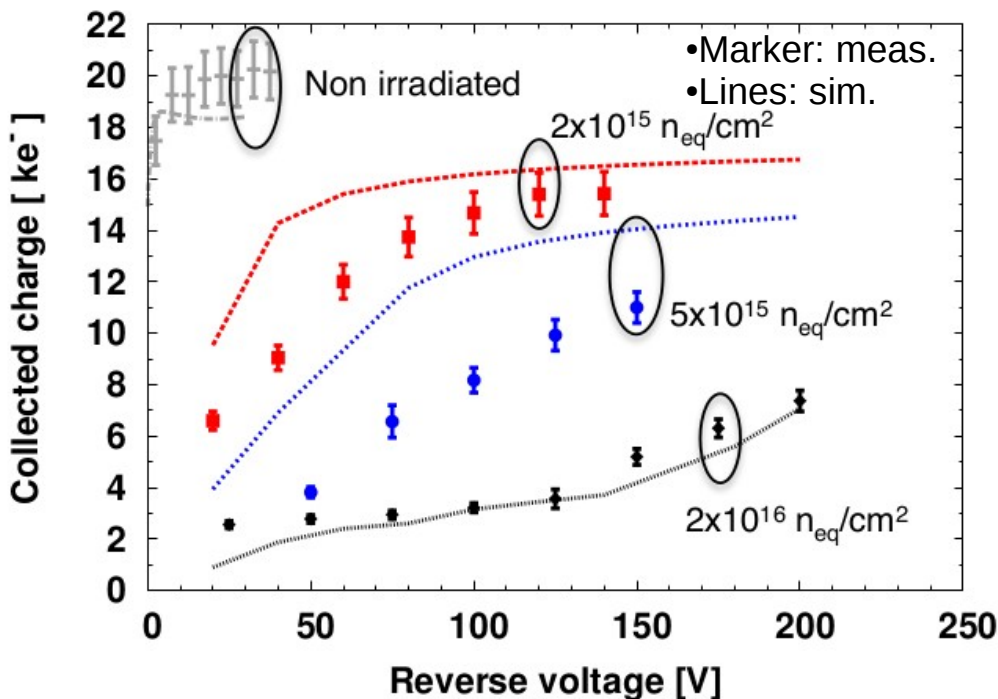


- With high irradiation, strict clustering but clear peak.
- Pretty large clusters at high voltage (narrow pitch).

Experimental results and discussion

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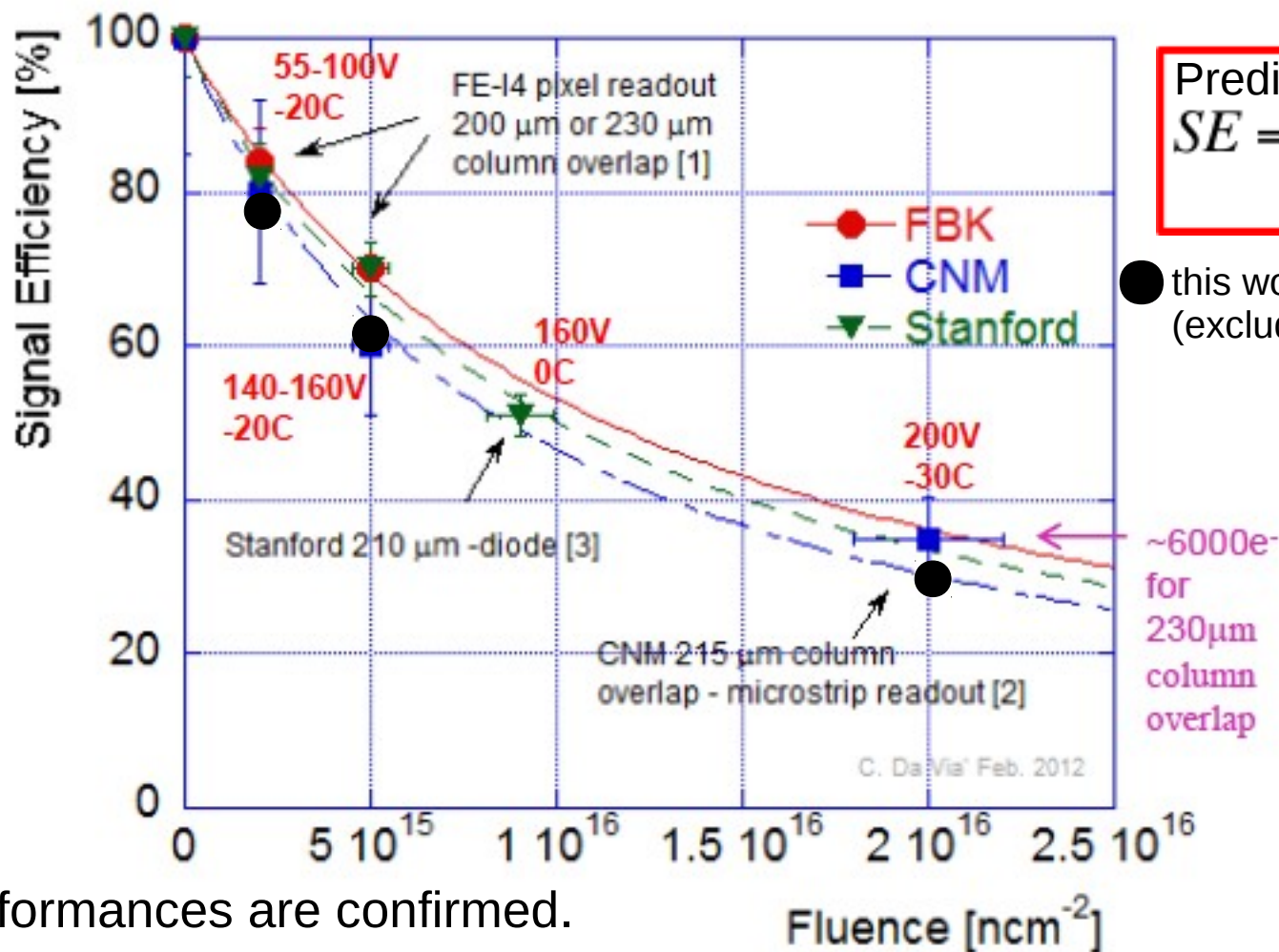
• β -source: charge collection versus bias



- Charge collection in agreement with simulations. Significant also at low voltages (see 20 V, 2*10¹⁵ n_{eq}/cm²).
- No charge multiplication (maybe at 2*10¹⁶ n_{eq}/cm²).
- Noise dominated by electronics, leakage current? (Interstrip/bulk capacitance<10%.)

Experimental results and discussion

• β -source: performances comparison



- Performances are confirmed.

[1] ATLAS IBL Coll., Jinst 7, 2012.

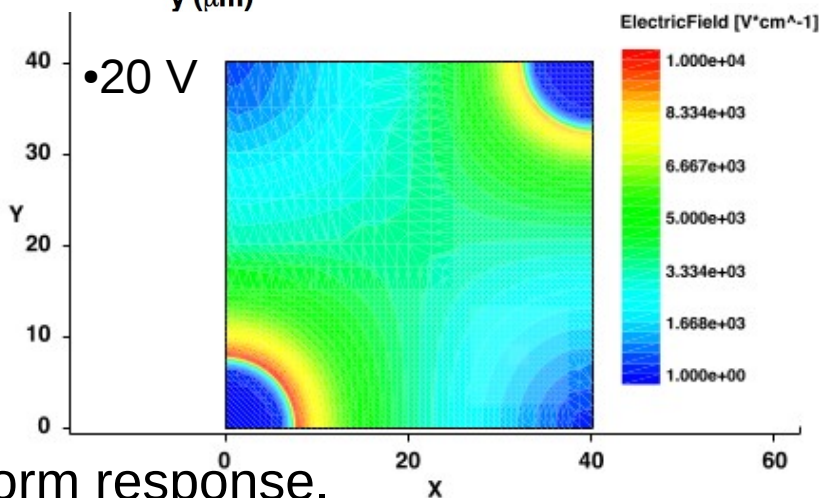
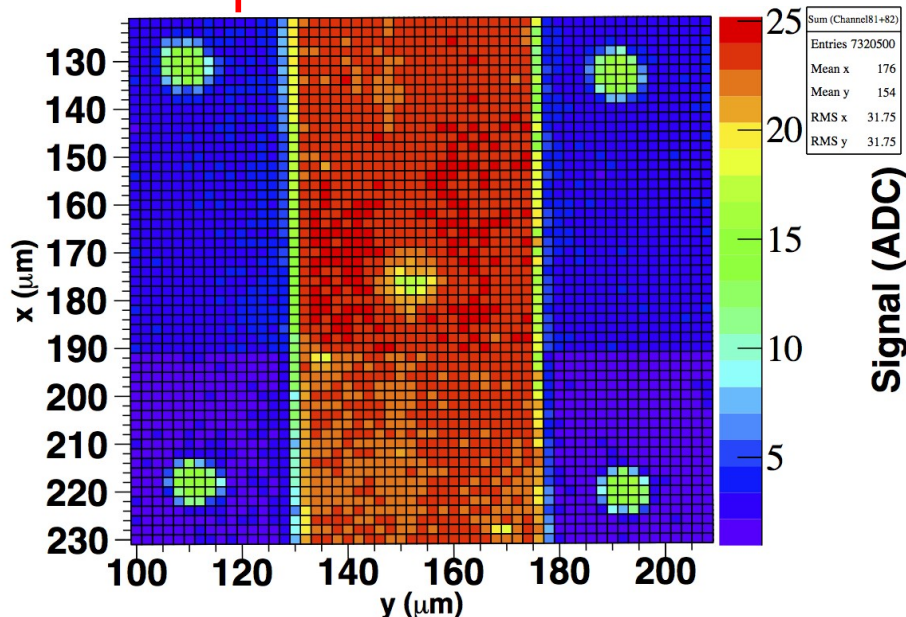
[2] Köhler et al., NIMA 659, 2011.

[3] Da Via et al., NIMA 604, 2009.

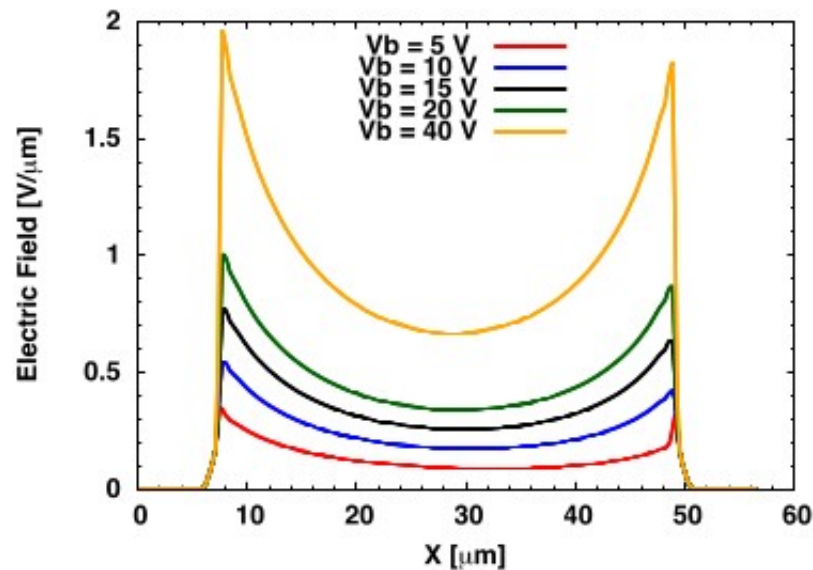
Experimental results and discussion

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• Laser: pre-irradiation: results and simulations



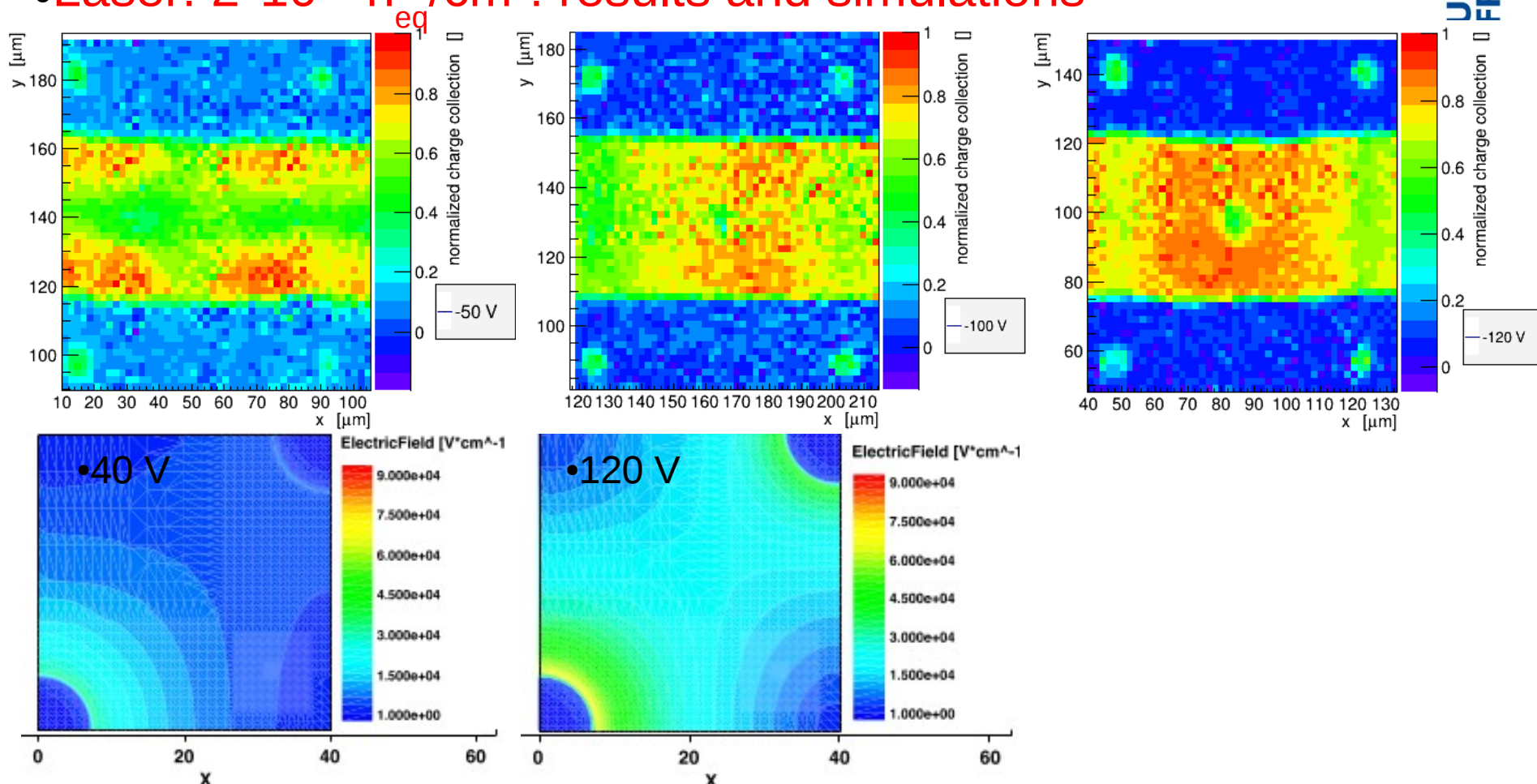
• Uniform response.



Experimental results and discussion

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- Laser: $2 \cdot 10^{15} \text{ n}_{eq} / \text{cm}^2$: results and simulations

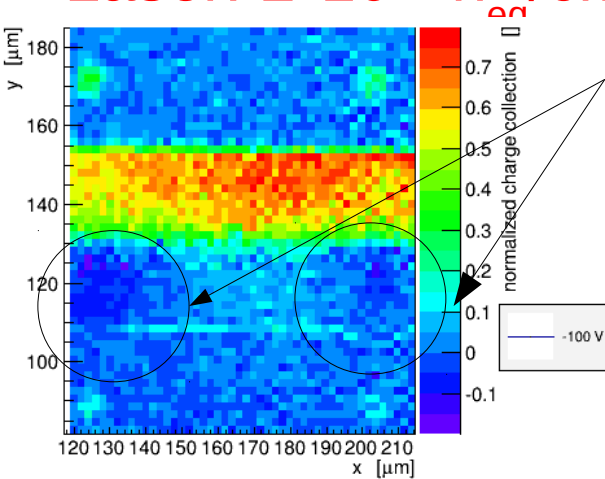


- Significant change with bias: collection from junction columns to in between those of the same strip => “compensation” effect: sum for same strip, subtraction for neighbours.

Experimental results and discussion

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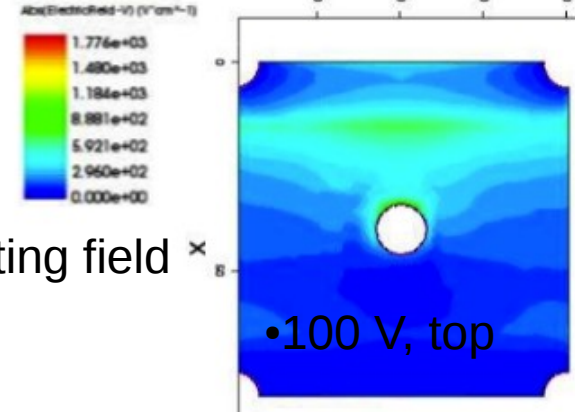
- **Laser: $2 \cdot 10^{15} \text{ n/cm}^2$: discussion: "compensation" effect**



Large negative zones

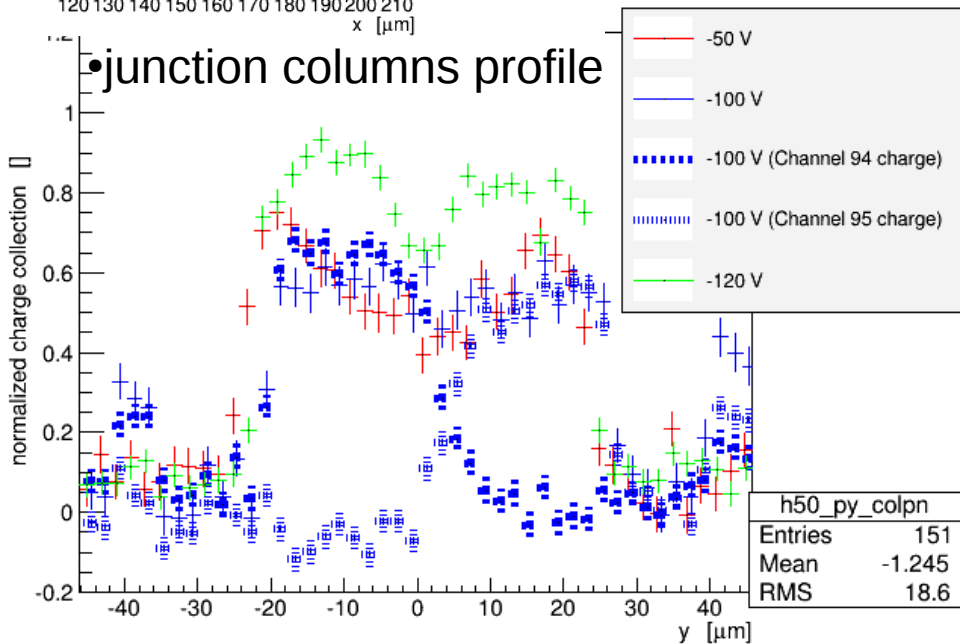
From Ramo's Th.

- $E_w \sim < 0$
- $E \ll 0$
- $vel < 0$
- $\Rightarrow I(t:low) < 0$

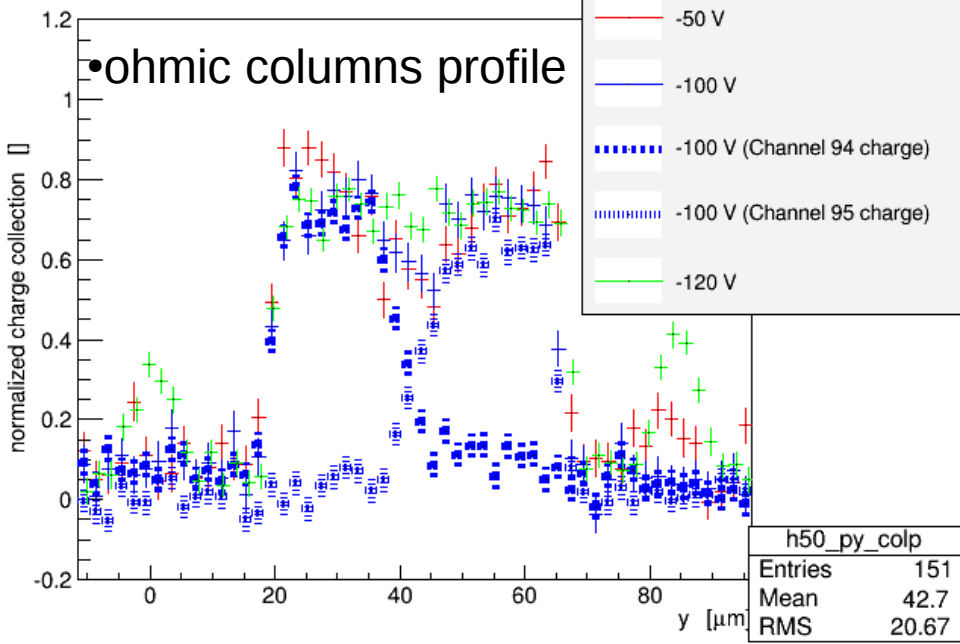


- Weighting field

• 100 V, top



- junction columns profile



- ohmic columns profile

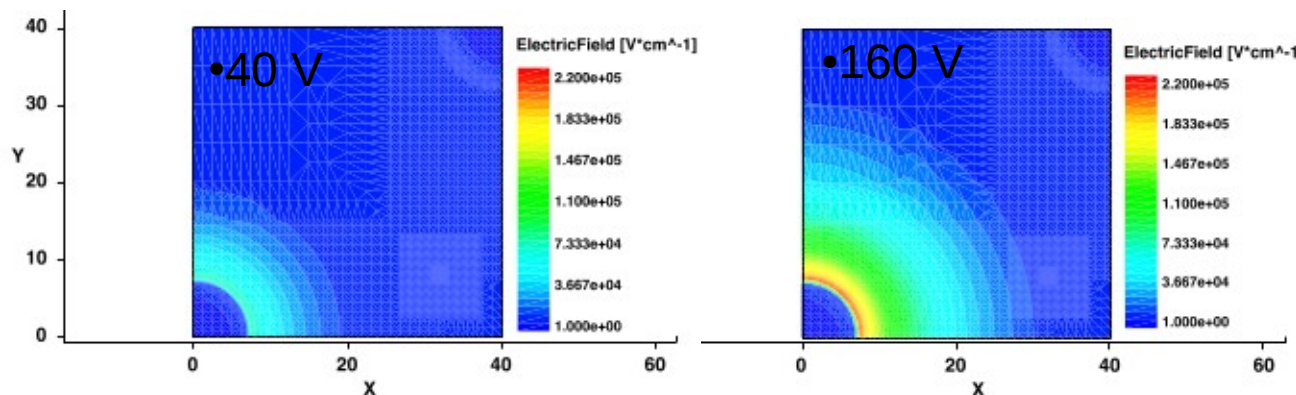
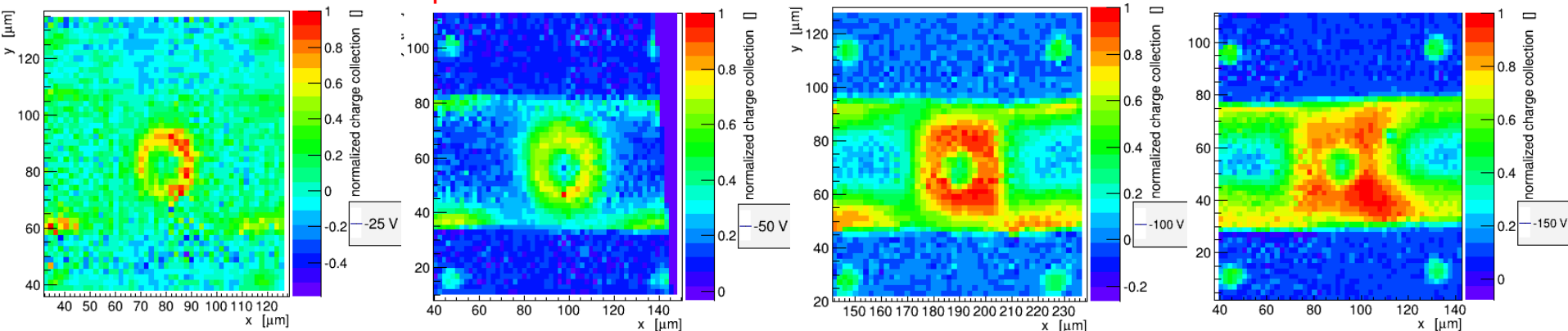
- Significant compensation effect due to limited integration time and hole deficit[1].

[1] Pöhlsen, RD50 workshop talk 2013.11.14, Experimental study of the Si-SiO2 interface region...

Experimental results and discussion

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- Laser: $2 \cdot 10^{16} \text{ n}_{\text{eq}} / \text{cm}^2$: results and simulations

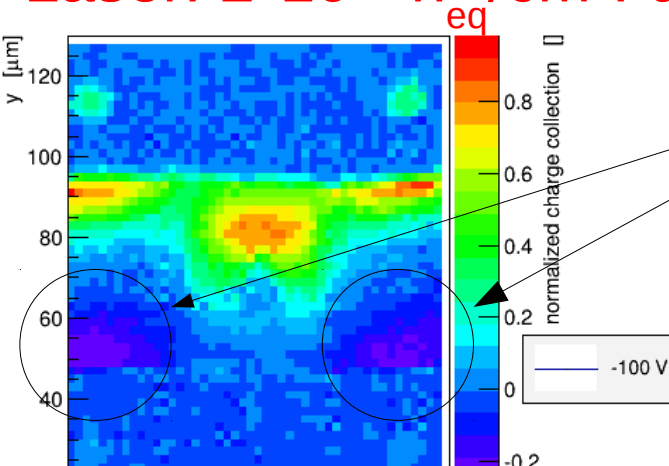


- Large dead zones also at 160 V (with ~20% collection).
 - NOTE: collecting 5 ke- at 150 V, an average unit cell collection of 50% means peaks collecting effectively 10 ke-!
- Significant collection at the ohmic columns also at low voltage. Double-junction on p-type??? Not predicted!

Experimental results and discussion

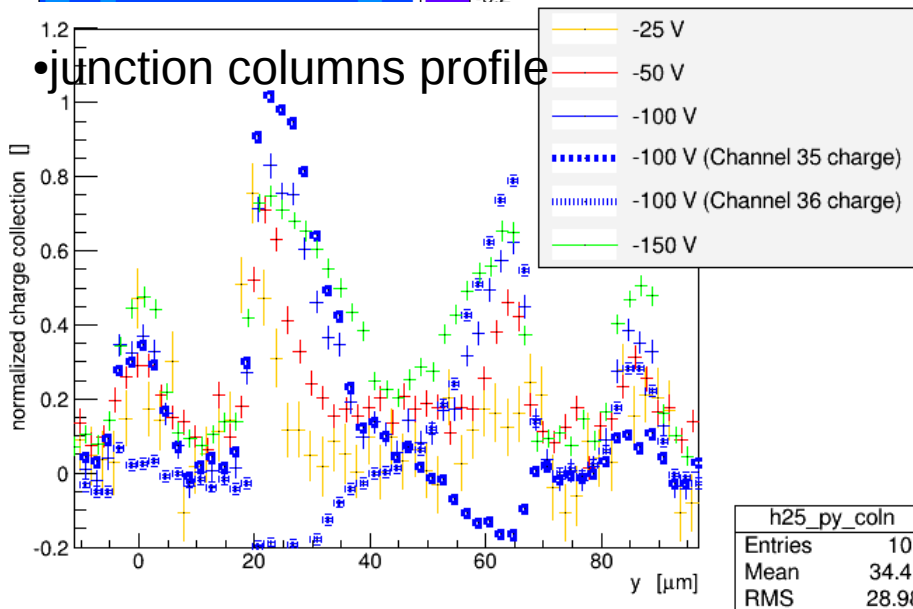
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- Laser: $2 \cdot 10^{16}$ n /cm²: discussion: “compensation” effect

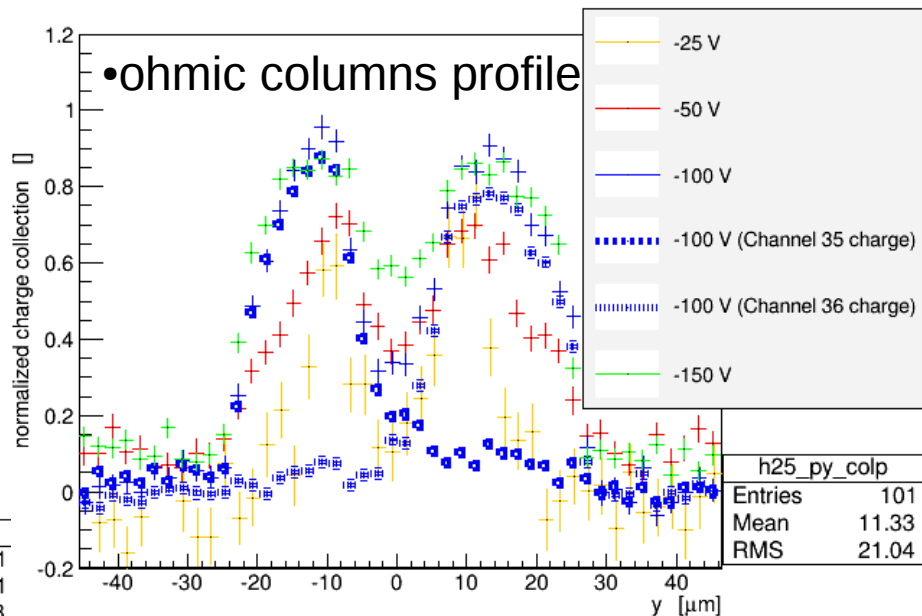


Very large and very negative zones

- junction columns profile



- ohmic columns profile



- Larger than at lower fluence: relatively higher field distributed closer to the junction columns.

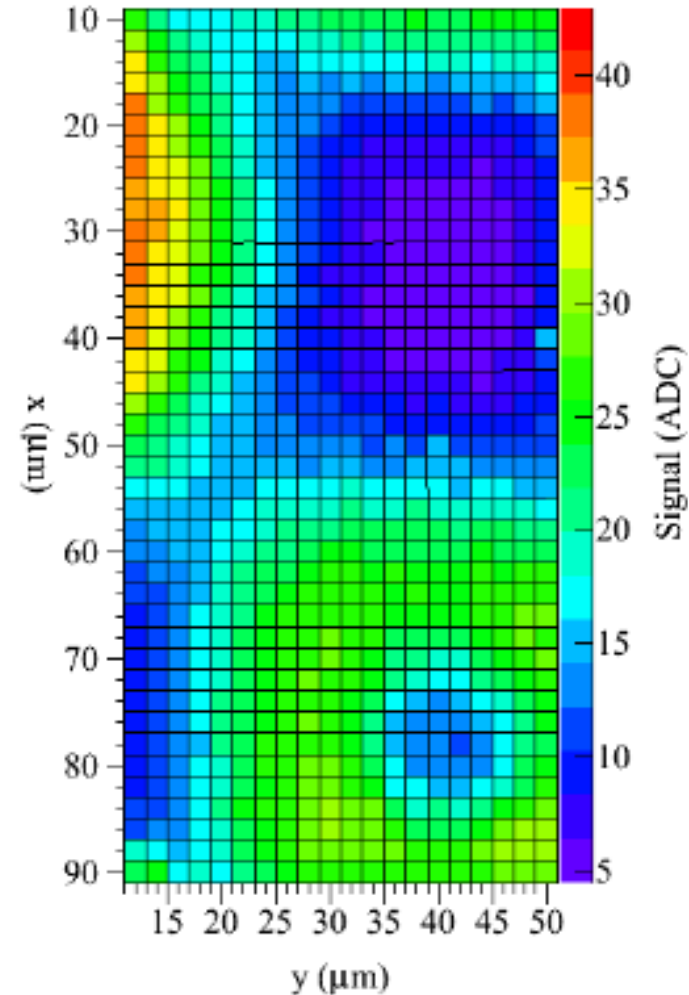
Experimental results and discussion

- Laser: $2 \cdot 10^{16} n_{eq}/\text{cm}^2$: comparison with CNM sensors

- 3D irradiated at KIT.
- ~285 μm thickness, ~215 μm columns overlapping.
- ~56 μm column pitch
- Same set-up.

- $2 \cdot 10^{16} n_{eq}/\text{cm}^2$.
- 100 V.

- (Measured charge multiplication.)
- Similarly high collection at the ohmic columns.

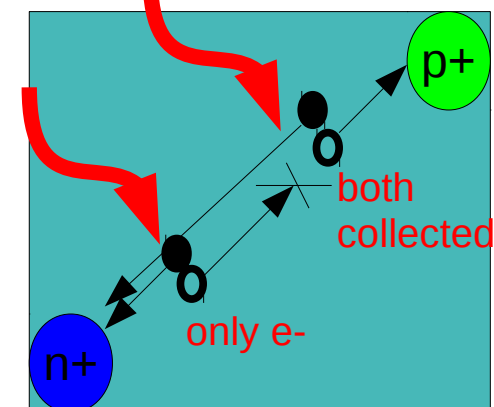
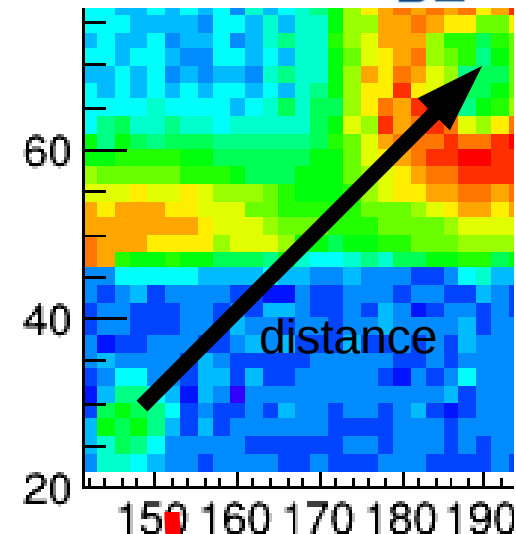
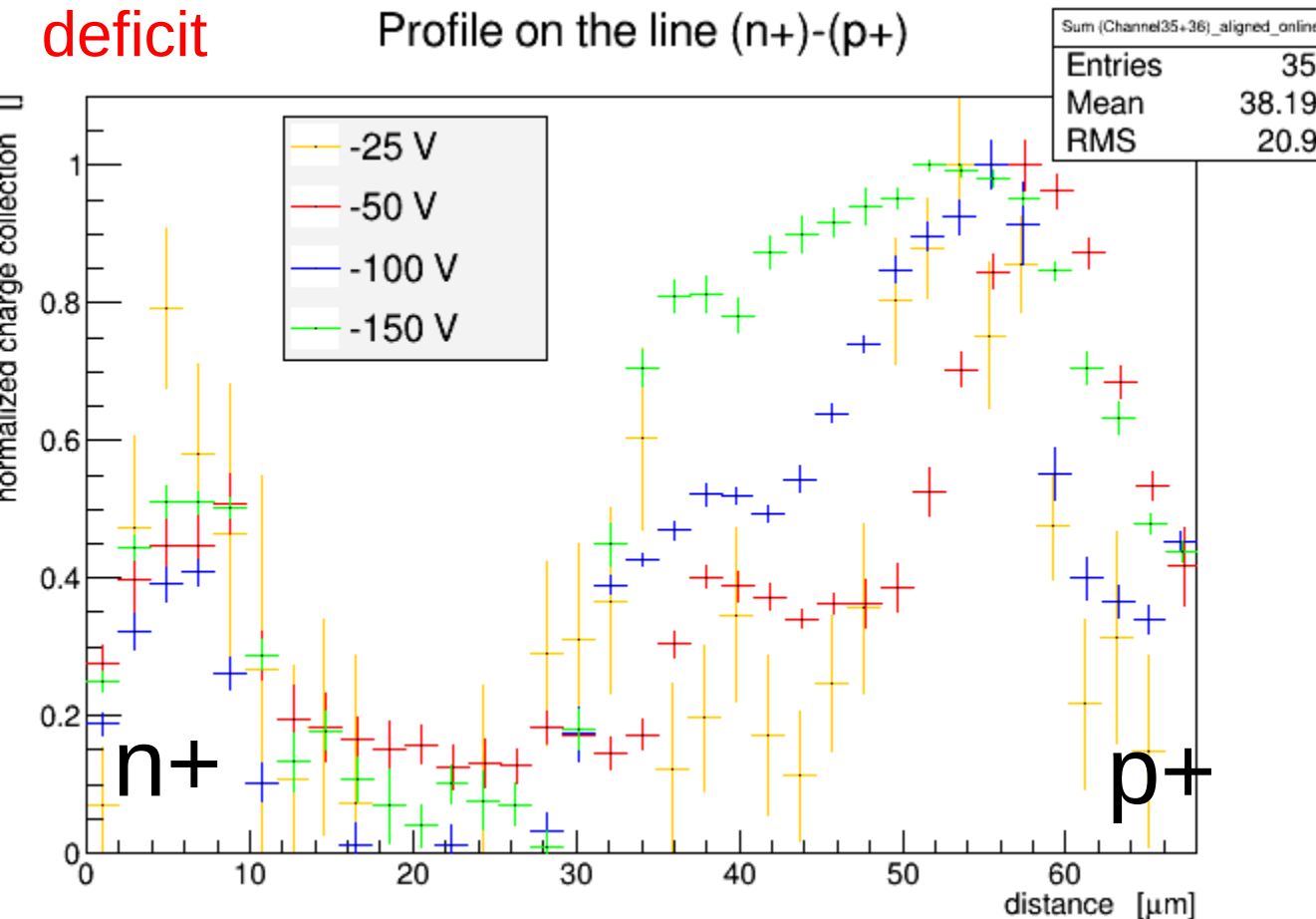


[1] Köhler et al., NIMA 659, 2011.

Experimental results and discussion

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- Laser: $2 \cdot 10^{16} n_{eq} / \text{cm}^2$: discussion: hole trapping and ballistic deficit



- With the low field, the slower holes are not integrated and are more prone to recombine. Increasing the bias, the effect is reduced.

• Motivations:

- Test radiation hardness up to $2 \cdot 10^{16} \text{ n}_{\text{eq}} / \text{cm}^2$: charge collection, spatial uniformity.

• Results:

- New sensors DTC: reasonable increase in the breakdown voltage before and after irradiation achieved.
- Punch-through effective at $2 \cdot 10^{15} \text{ n}_{\text{eq}} / \text{cm}^2$.
- Charge collection as expected. Significant also at low voltages (6 ke- @ 20 V, $2 \cdot 10^{15} \text{ n}_{\text{eq}} / \text{cm}^2$). No charge multiplication observed.
- Collection still far to be uniform at high irradiation fluences:
 - Compensation effect due to limited integration time and holes deficit.
 - For $2 \cdot 10^{15} \text{ n}_{\text{eq}} / \text{cm}^2$ increasing the bias the highest collection moves from around the junction columns to in between them; still due to compensation.
 - High collection close to the ohmic columns: determined by the amount of the holes contribution to the overall signal (how big deficit).

• Outlook:

- Smaller inter-electrode spacing to have more uniform collection at lower voltages. Higher break-down voltage needed (encouraging results in new FBK samples[1]).
- Changing integration time to investigate the compensation effect and the hole deficit.
- Test beam or X-rays!!!

[1] Dalla Betta et al., IEEE NSS N41-1, 2013.

Summary and outlook

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Thank you!!!

[1] Dalla Betta et al., IEEE NSS N41-1, 2013.

- Sensor details.
- Clustering effect.
- Hole deficit for $2 \cdot 10^{15} n_{eq} / \text{cm}^2$.
- Tilted cell.

- **Coupling details:**

- AC: biased by punch-through from the bias line and have integrated coupling capacitors
- DC: can be used via an external R-C fan-in ($R = 1 \text{ M}\Omega$, $C = 275 \text{ pF}$).

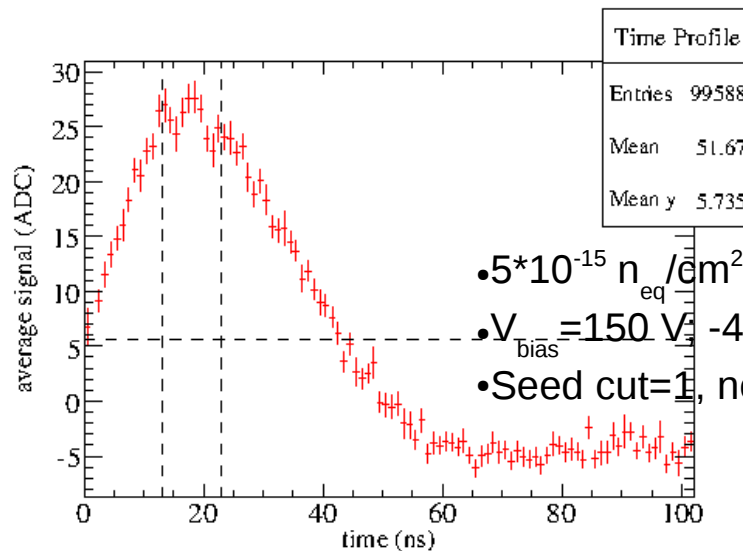
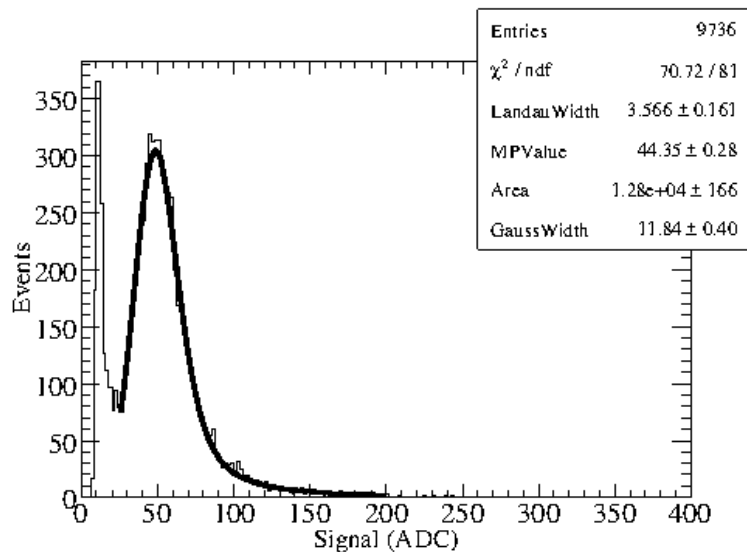
- **Methods details:**

- Results were qualitatively similar, but in the AC configuration, the non-optimized thickness of the coupling oxide layer (which is about $1 \text{ }\mu\text{m}$ due to other process constraints) caused the coupling capacitance ($\sim 8 \text{ pF}$) to be insufficient, and higher signal and signal/noise values were obtained by using R-C chips. Thus, although the punch-through bias was proved to properly work also after irradiation, all functional tests discussed here were carried out by using external R-C chips.

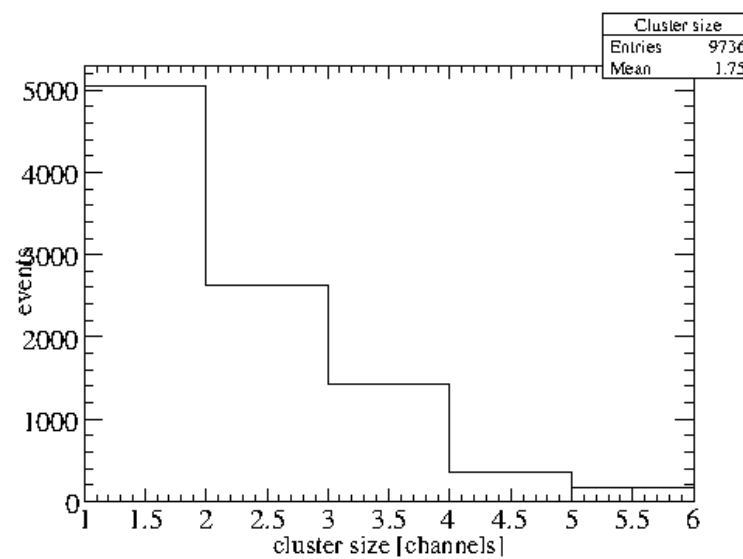
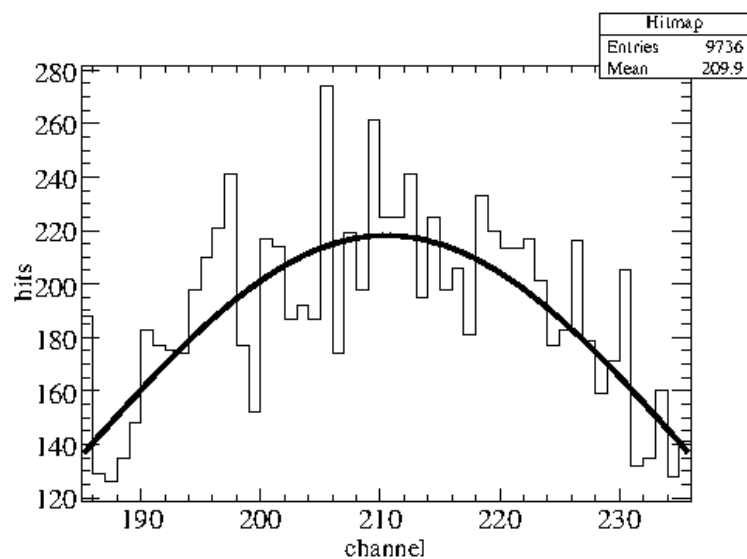
Spares: clustering effect (1)

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- β -source: pulse, spectrum, spatial distribution, clustering



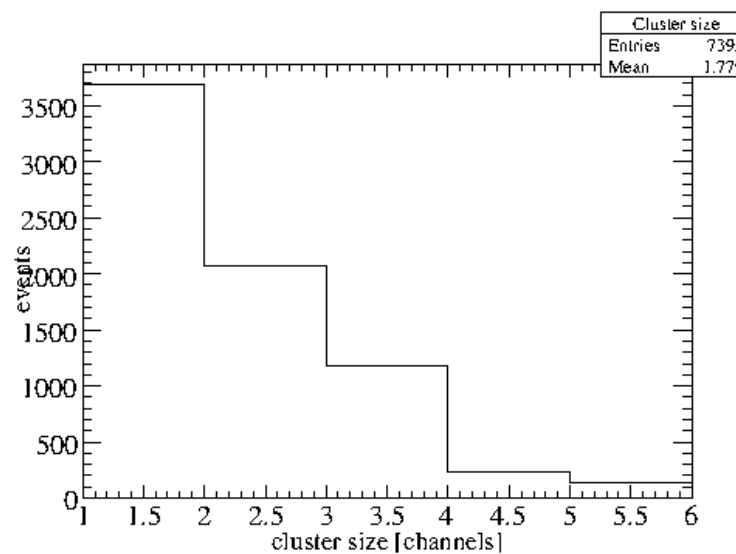
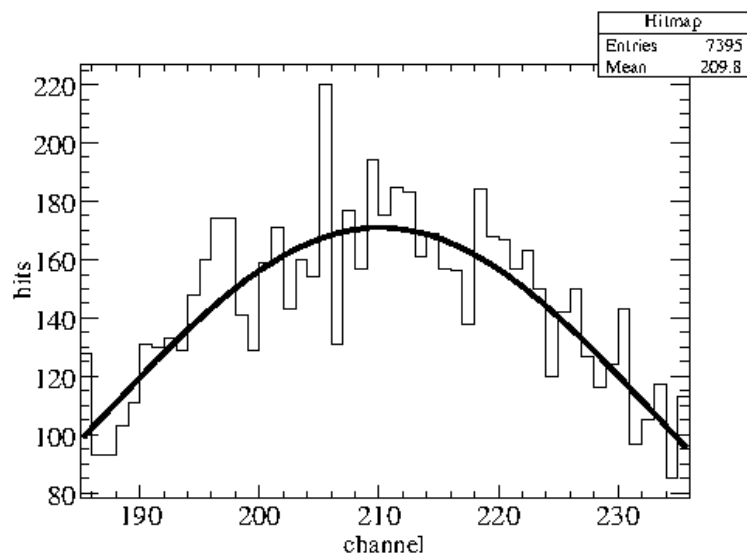
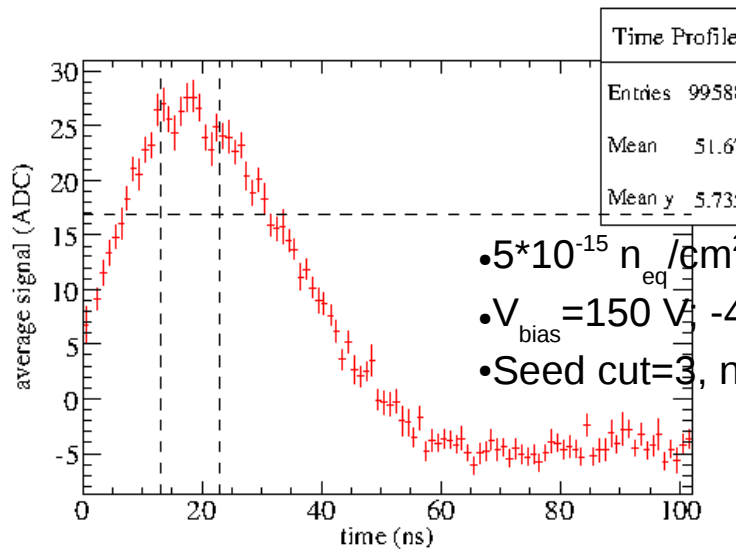
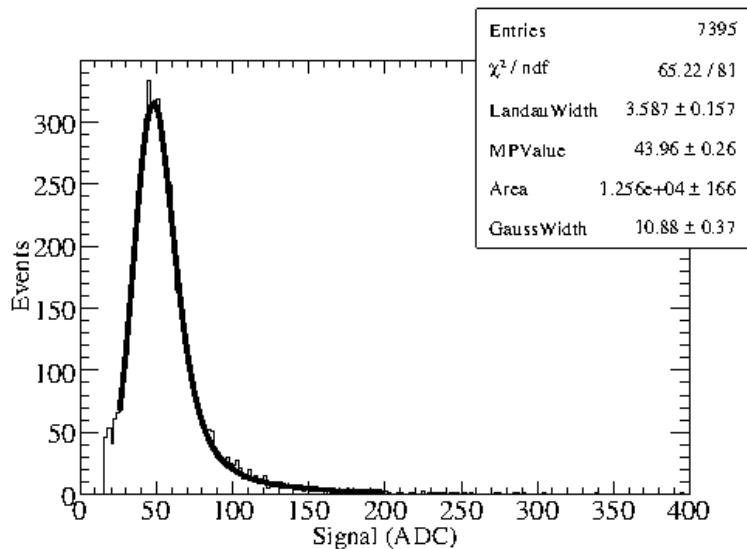
- $5 \cdot 10^{-15} \text{ n}_{\text{eq}} / \text{cm}^2$.
- $V_{\text{bias}} = 150 \text{ V}$ -40 +/- 2 °C.
- Seed cut=1, neighbour cut=1.



Spares: clustering effect (2)

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- β -source: pulse, spectrum, spatial distribution, clustering



Spares: hole deficit at $2 \cdot 10^{15} n_{eq}/cm^2$

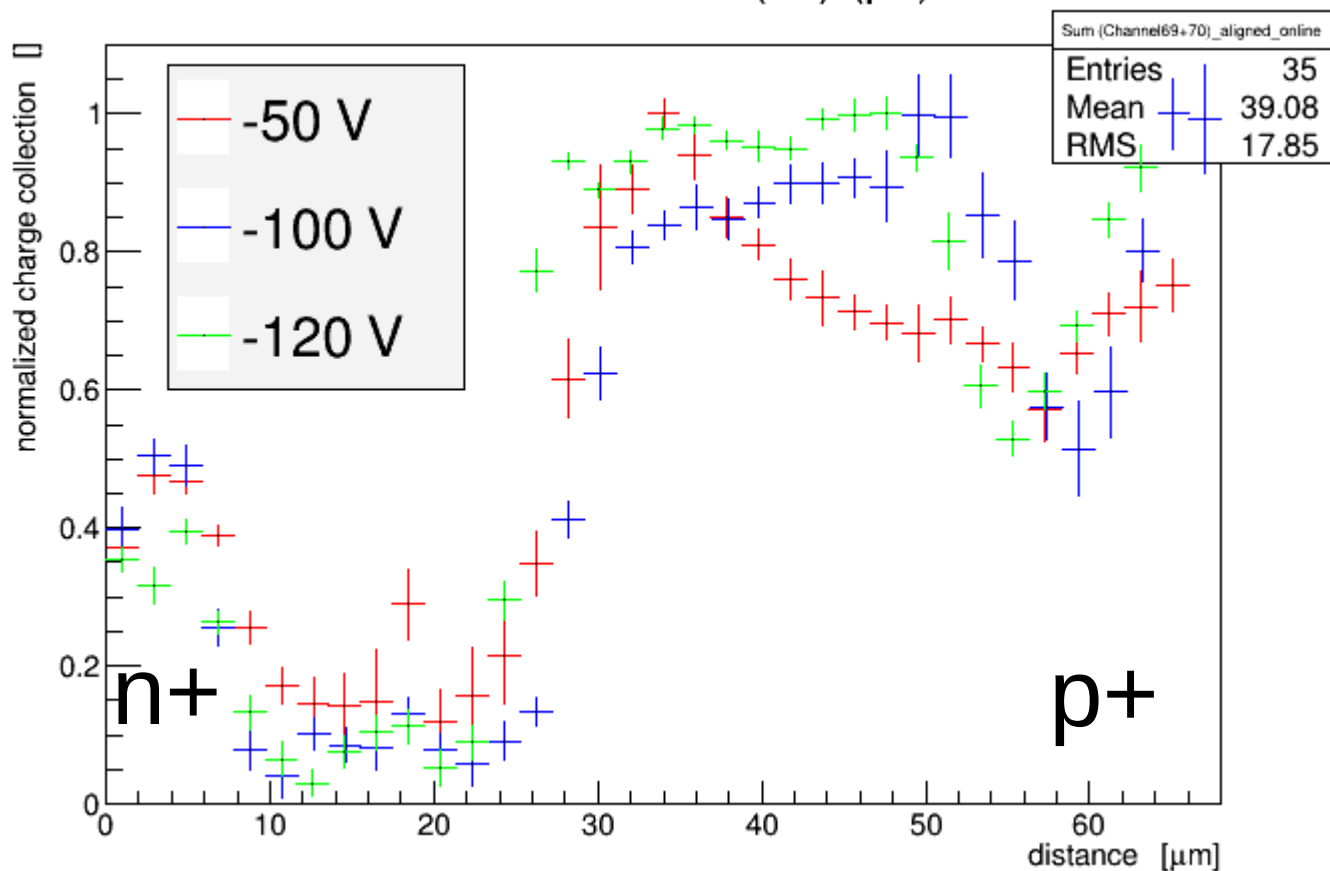
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- Laser: $2 \cdot 10^{15} n_{eq}/cm^2$: discussion: hole trapping and ballistic deficit

Profile on the line (n+)-(p+)

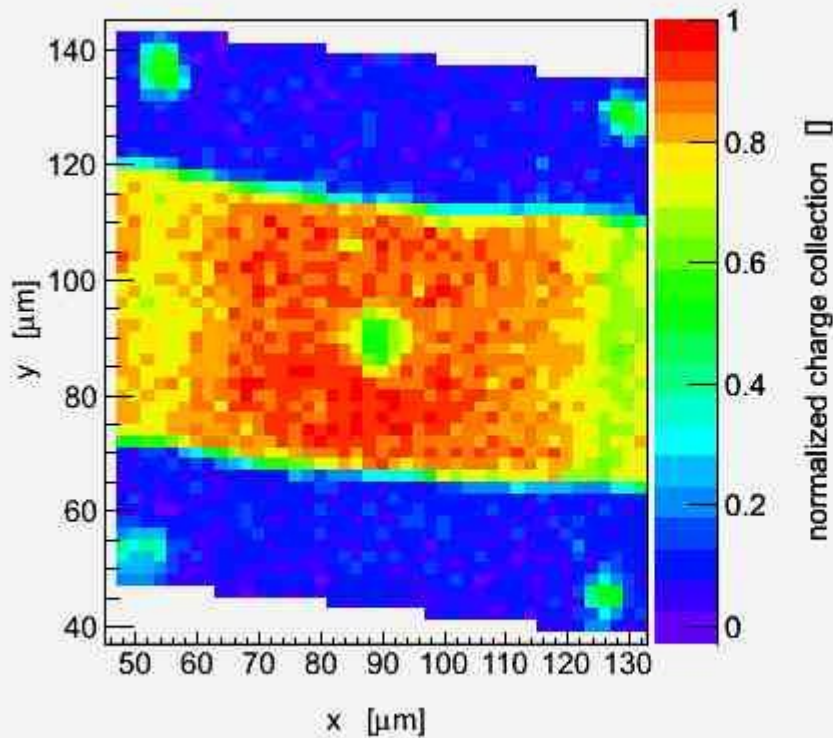


- Before depletion, holes still collected and/or much lower electron contribution close to the ohmic columns (relative collection!!!).

Spares: tilted cell

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Sum (Channel69+70)



Sum (Channel69+70)

Entries	1.139767e+07
Mean x	89.01
Mean y	91
RMS x	25.39
RMS y	31.17

$$\bullet 2 \cdot 10^{15} n_{eq} / \text{cm}^2$$

-120 V